(19) World Intellectual Property Organization

International Bureau





(43) International Publication Date 9 September 2005 (09.09.2005)

PCT

(10) International Publication Number WO 2005/082520 A1

(51) International Patent Classification⁷: **B01J 19/08**, B05B 1/02, F27D 15/00

(21) International Application Number:

PCT/SG2005/000057

(22) International Filing Date: 28 February 2005 (28.02.2005)

(25) Filing Language: English

(26) Publication Language: English

(30) Priority Data: 200400806-6 28 February 2004 (28.02.2004) SG

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(81) Designated States (unless otherwise indicated, for every kind of national protection available): AE, AG, AL, AM,

AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SM, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW.

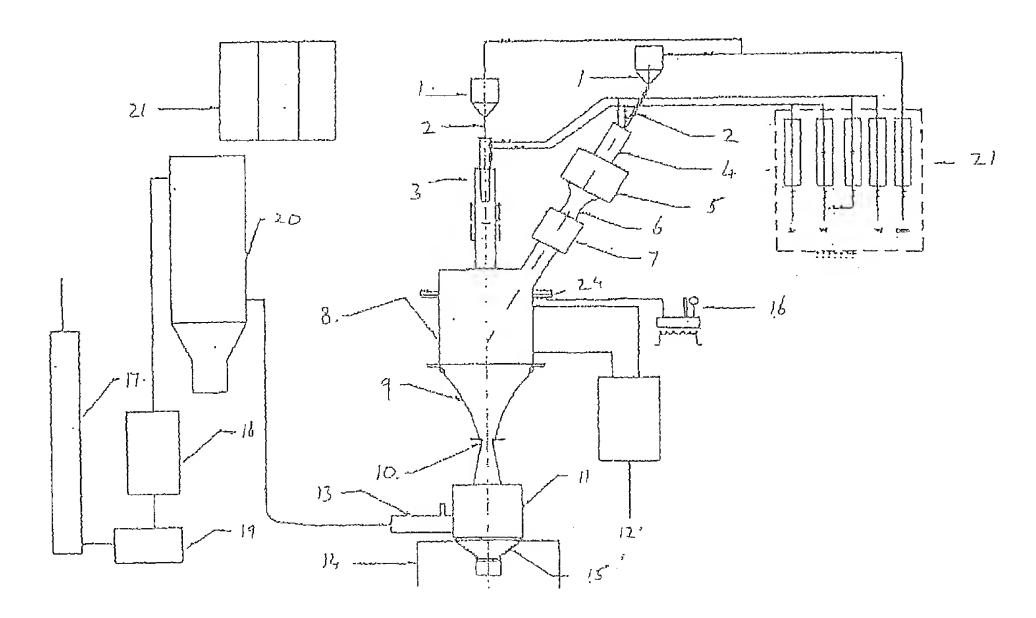
(84) Designated States (unless otherwise indicated, for every kind of regional protection available): ARIPO (BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IS, IT, LT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

Published:

with international search report

For two-letter codes and other abbreviations, refer to the "Guidance Notes on Codes and Abbreviations" appearing at the beginning of each regular issue of the PCT Gazette.

(54) Title: FINE PARTICLE POWDER PRODUCTION



(57) Abstract: The present invention relates to a vapourised flow quenching reactor for producing a fine-powder from one or more reactant materials. The reactor comprises a first heat creating means selected from one of a DC plasma torch (4) and RF plasma torch (3), a first reaction chamber (5) within which energized reactant materials react and a first convergent-divergent nozzle (6) for quenching the heated reactant materials from the first reaction chamber (5). The reactor also comprises a second reaction chamber (8) provided for congregation of nano particles formed therefrom and a second convergent-divergent nozzle (9) to deliver the nano particles to a collection chamber (11).

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